Application No.: 09/912,558 Docket No.: M4065.0319/P319-A

## **AMENDMENT TO THE SPECIFICATION**

Please amend the Title of the Invention as follows:

FABRICATION OF DRAM AND OTHER SEMICONDUCTOR DEVICES WITH AN INSULATING FILM USING A WET RAPID THERMAL OXIDATION PROCESS METHOD OF FABRICATING A SEMICONDUCTOR DEVICE WITH A WET OXIDATION WITH STEAM PROCESS